

Fig 2

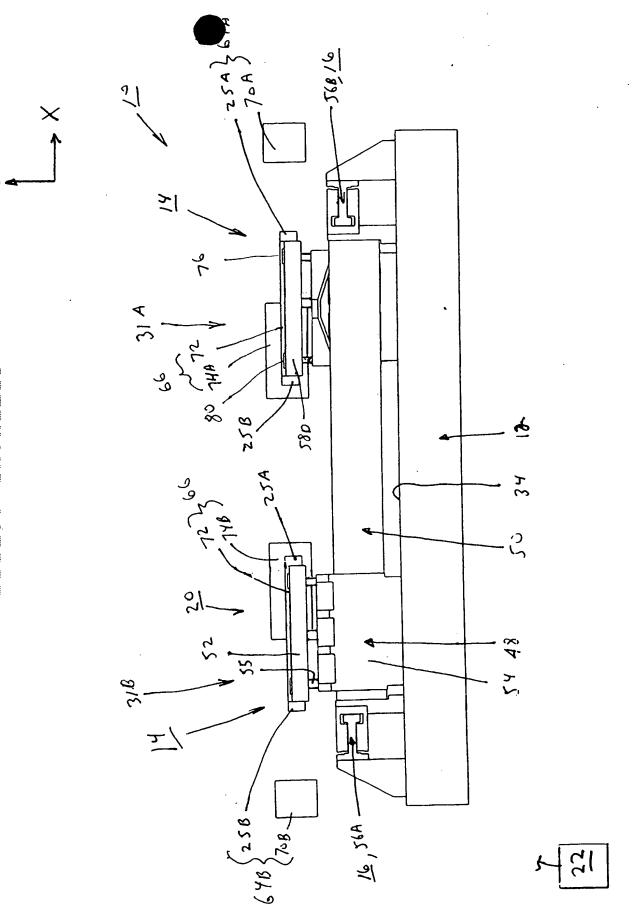
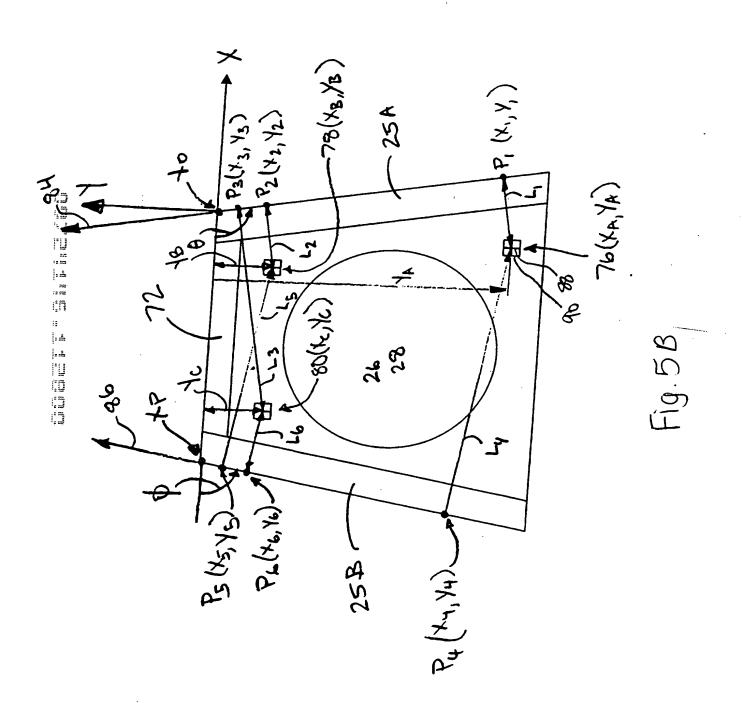
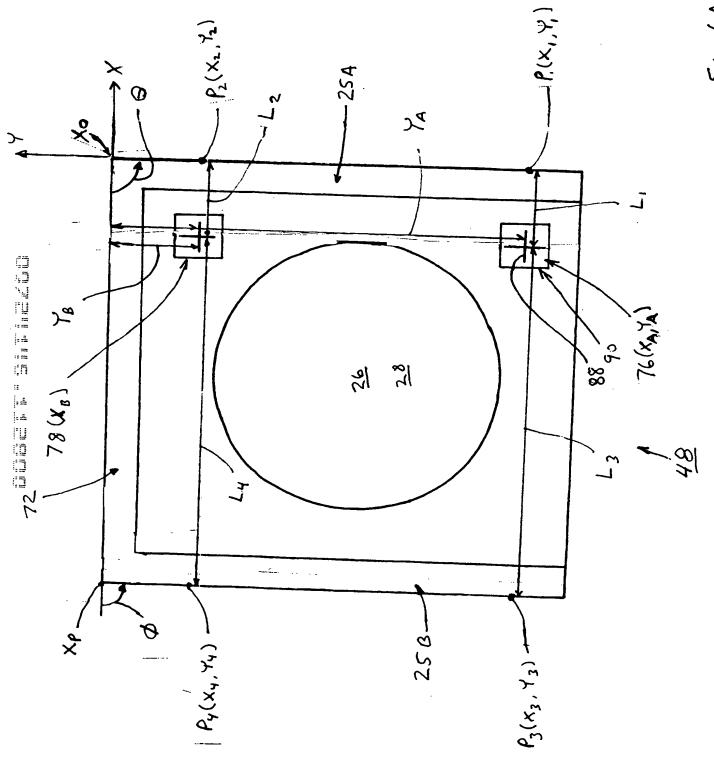


Fig. SA





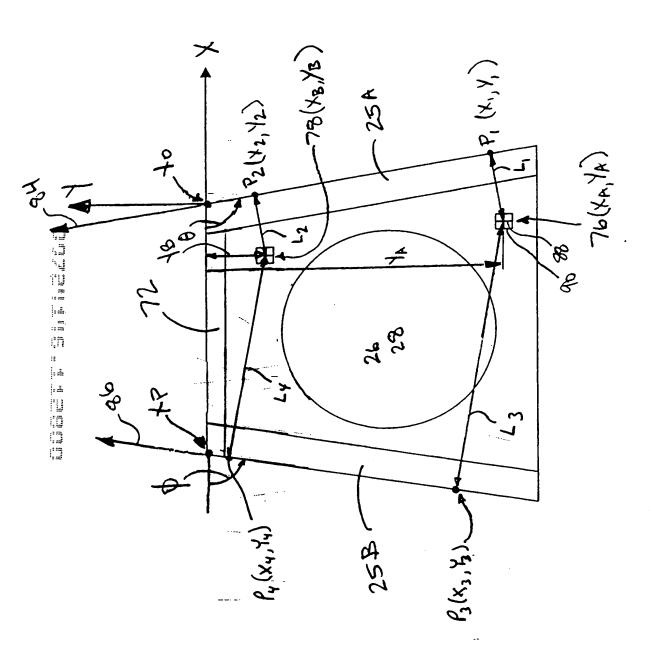
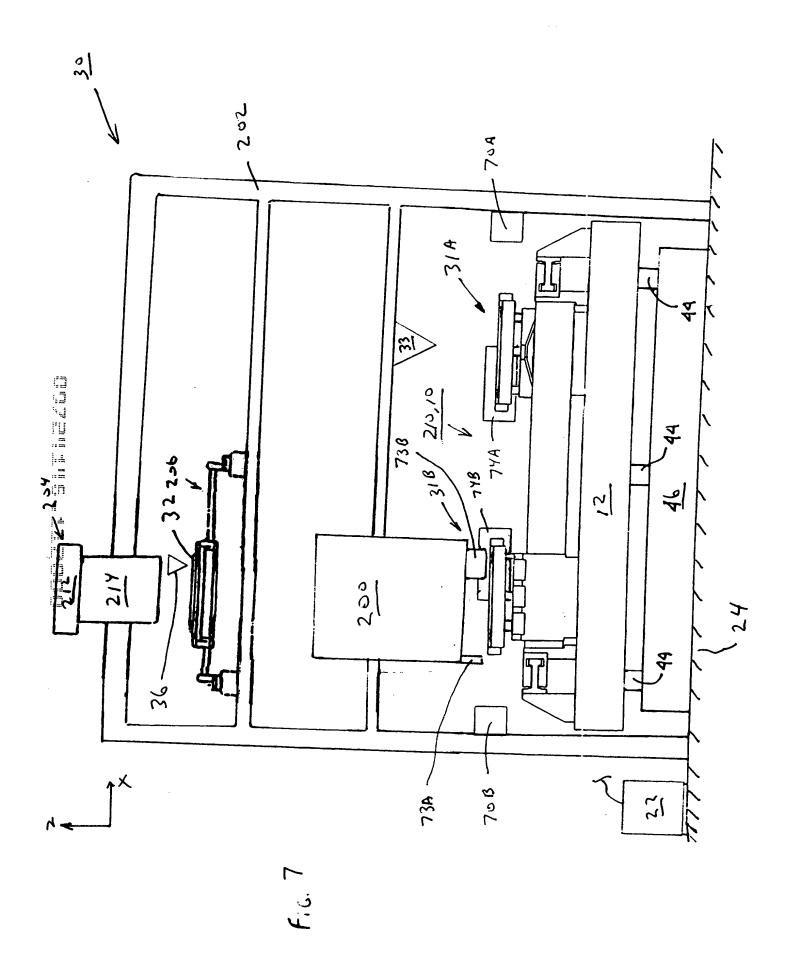
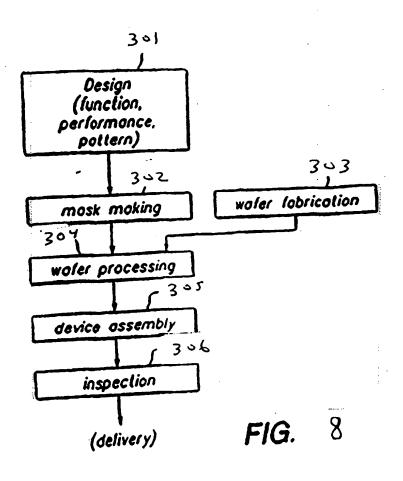


Fig. 6 B





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